

External User Registration Form

DATE:	/ /		EXTERNAL USER Nº:		
User Name and Surname:					
Institution/Company Name:					
Department/Group:					
ID Card nº (DNI):					
Job Position:					
Phone Number:					
E-mail:					
BILLING DETAILS (fiscal data):					
Customer Name and Surname (PI):					
Full name of the Institution or Company:					
Vat Number (NIF):					
Business Address (Address, PC, City and Country)					
Phone Number:					
Fax:					
E-mail:	1				
FORM	OF PAYMENT – TRANSFER	IN CASH:	TO 30 DAYS:		
Billing Address (if it is different of the Business Address):					
Addres	ss:				
Signature and Institution Stamp:					
			In compliance with Law 15/1999 of Dece Personal Data (LOPD), we inform you that the voluntarily in this form will be added and/of by Catalan Institute on Nanoscience and established in Campus UAB, 08193 Bellaterrated delivery, training and dissemination seminated may exercise your rights of access, rectification by sending an email to the address	ne personal data provided r updated in a file owned Nanotechnology (ICN2), a aimed to manage service ars. At any moment, you dication, cancellation and	

I consent to receive by email scientific and technical information as well as information about courses or seminars organized by ICN2. YES NO

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email: raul.perez@icn2.cat

Facility Officer: Raúl Pérez

Phone: 93 737 3645

Office: 1030



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Select the equipment intended to be used:

Direct Write Laser Lithography				
Mask Aligner UV Photolithography				
Nanoimprint Lithography (NIL)				
E-beam thin film evaporator				
ICP- Reactive Ion Etching (ICP-RIE)				
Sputter Coater (Au)				
Plasma Cleaner (O ₂)				
Wet bench				
Oven/Hot plates				
Spinner				
Stylus Profilometer				
3D Optical Profiler				
Optical Microscope				
AFM				
EBL				
FIB				

TERMS AND CONDITIONS:

Signing this document implies that:

- 1.- The user has read the documentation related to the rules and conditions of use of the Nanofabrication Facility. http://www.icn2.cat/nanofabrication/nanofab.html
- 2. The user must cite the Nanofabrication Facility in publications arising from the service provided.
- 3. ICN2 is not responsible for property and/or personal damage arising from misuse of facilities and/or violation of safety rules and emergency plan of the building.
- 4. Violation of these rules will result in the loss of rights of use of the equipment and services of the Nanofabrication Facility.